

Coating and thin film thickness analyzer (TFM-200)



■ TFM-200 Series

TFM-200 Series is a non-contact coating and thin film thickness analyzer. It is sometimes called as reflectometer.

TFM has a user friendly interface which helps anybody can get results easily.

■ Specifications at a glance

*Measurement range: $0.5 \mu m$ to $400 \mu m$ (depending on film type)

*Measurement spot size: 40 μ m, 80 μ m (8 μ m optional)

*Stage size: 140 x 132 mm (X-Y movement 75 x 50 mm)

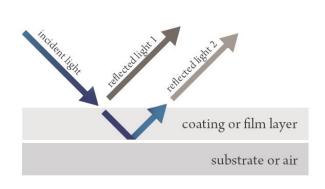
*Dimensions: 22 x 22 x 7 cm (microscope: 15cm x 20 cm x 50 cm)

Specifications

TFM-200N

| Thickness range | $0.5~\mu\text{m}-100~\mu\text{m}$ | 1 μ m $-$ 400 μ m | | |
|------------------|---|---------------------------|--|--|
| Wavelength range | 350 nm — 1,050 nm | 750 nm — 1,100 nm | | |
| Spot size | 40 μ m, 80 μ m (8 μ m optional) | | | |
| Repeatability | <± 0.001 μ m at 1 μ m SiO2 on Si wafer | | | |
| Light source | Tungsten halogen 35 W | | | |
| Sample stage | 140 mm x 132 mm (X-Y movement 75 x 50 mm) | | | |
| Dimensions | Detector: 22 cm × 22 cm × 7 cm (H) Microscope: 15 cm x 20 cm x 50 cm (H) | | | |
| Weight | Approxim | approximately 20 kg | | |
| Power | 110 or 22 | 110 or 220 V / 0.5 A | | |

■ Principle



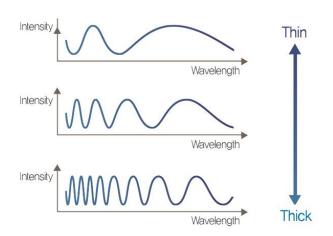


Fig 1. Principle

Fig. 2. Principle 2

When the incident light directs light into the sample, some part of the light is reflected back from the film's surface (reflected light 1) and some part transmits the film and is reflected back from the substrate (reflected light 2) (Fig. 1).

There are interference phenomena between the two reflected lights as shown in Fig. 2. Fig. 2 indicates that the more the sine curves in the graph, the thicker the film.

■ Thickness Results

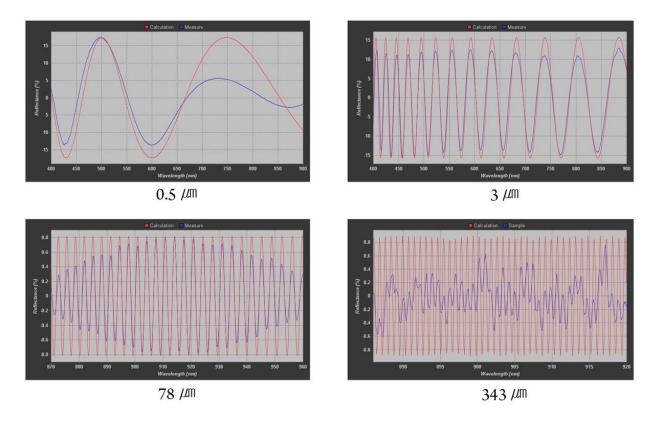


Fig. 3. Thickness results

| No | Thickness | N | 0 | Thickness |
|--------|-----------|----|---|--------------------|
| 1 | 0.5124 | 1 | | 77.98 |
| 2 | 0.5124 | 2 | ! | 77.98 |
| 3 | 0.5124 | 3 | ; | 77.98 |
| 4 | 0.5125 | 4 | | 77.98 |
| 5 | 0.5124 | 5 | i | 77.98 |
| 6 | 0.5124 | 6 | | 77.98 |
| 7 | 0.5124 | 7 | | 77.98 |
| 8 | 0.5124 | 8 | | 77.99 |
| 9 | 0.5124 | 9 | | 77.99 |
| 10 | 0.5124 | 1 | 0 | 77.98 |
| 500 nm | | 33 | | $78~\mu\mathrm{m}$ |

Fig. 4. Repeatability (10 times)

Applications

- Semiconductor
- Display
- Conductive oxides
- Protective coatings
- PCB coating process
- Parylene coatings
- Hard coatings
- Lens coatings
- ■Bio medical applications
- Adhesive coatings
- ■Polymer films (ex. PET)
- ■Thick photo-resists (ex. SU-8)





